		•			Docket Number (Optional)	14	Application Number			
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	E INFORMATION DISCLOSURE CITATION (Use several sheets if necessary)				Applicant(s) Yan Wang et al.					
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Surah ylong					DATE CONSIDERED 19 MAR 03					
XAMINER	: Initial	if citation considered, whether o	r not citation is in c	onformance			citation if not in	n conforma	nce and	
ot considered. Include copy of this form with next communication to applicant.										

Form PTO-A820 (also form PTO-1449)